Investigation of the material removal characteristic for polishing CoCr alloy

Original Citation


This version is available at http://eprints.hud.ac.uk/9333/

The University Repository is a digital collection of the research output of the University, available on Open Access. Copyright and Moral Rights for the items on this site are retained by the individual author and/or other copyright owners. Users may access full items free of charge; copies of full text items generally can be reproduced, displayed or performed and given to third parties in any format or medium for personal research or study, educational or not-for-profit purposes without prior permission or charge, provided:

- The authors, title and full bibliographic details is credited in any copy;
- A hyperlink and/or URL is included for the original metadata page; and
- The content is not changed in any way.

For more information, including our policy and submission procedure, please contact the Repository Team at: E.mailbox@hud.ac.uk.

http://eprints.hud.ac.uk/
Future Technologies in Computing and Engineering

Proceedings of Computing and Engineering Annual Researchers' Conference 2010

CEARC’10

Edited By
Prof. Gary Lucas    Dr Zhijie Xu

Organising Committee
Prof. Gary Lucas    Dr Zhijie Xu    Mrs Gwen Wood    Mrs Trudy Lockwood

Inspiring tomorrow’s professionals